

Hideki Hirayama

List of Publications by Year in descending order

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236925

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84
all docs

84
docs citations

84
times ranked

2215
citing authors

#	ARTICLE	IF	CITATIONS
1	Recent progress and future prospects of AlGaIn-based high-efficiency deep-ultraviolet light-emitting diodes. Japanese Journal of Applied Physics, 2014, 53, 100209.	1.5	464
2	The 2020 UV emitter roadmap. Journal Physics D: Applied Physics, 2020, 53, 503001.	2.8	289
3	Microassembly of semiconductor three-dimensional photonic crystals. Nature Materials, 2003, 2, 117-121.	27.5	273
4	Marked enhancement of 320–360 nm ultraviolet emission in quaternary $\text{In}_x\text{Al}_y\text{Ga}_{1-x-y}\text{N}$ with In-segregation effect. Applied Physics Letters, 2002, 80, 207-209.	3.3	141
5	Room-temperature operation at 333 nm of $\text{Al}_{0.03}\text{Ga}_{0.97}\text{N}/\text{Al}_{0.25}\text{Ga}_{0.75}\text{N}$ quantum-well light-emitting diodes with Mg-doped superlattice layers. Applied Physics Letters, 2000, 77, 175-177.	3.3	136
6	Intense photoluminescence from self-assembling InGaIn quantum dots artificially fabricated on AlGaIn surfaces. Applied Physics Letters, 1998, 72, 1736-1738.	3.3	128
7	Determination of photoluminescence mechanism in InGaIn quantum wells. Applied Physics Letters, 1999, 75, 2241-2243.	3.3	104
8	Stimulated emission from optically pumped GaIn quantum dots. Applied Physics Letters, 1997, 71, 1299-1301.	3.3	84
9	13 mW operation of a 295–310 nm AlGaIn UV-B LED with a p-AlGaIn transparent contact layer for real world applications. Journal of Materials Chemistry C, 2019, 7, 143-152.	5.5	84
10	Realization of high-efficiency deep-UV LEDs using transparent p-AlGaIn contact layer. Physica Status Solidi C: Current Topics in Solid State Physics, 2013, 10, 1521-1524.	0.8	78
11	Room-temperature intense 320 nm band ultraviolet emission from quaternary InAlGaIn-based multiple-quantum wells. Applied Physics Letters, 2002, 80, 1589-1591.	3.3	76
12	Novel surface emitting laser diode using photonic band-gap crystal cavity. Applied Physics Letters, 1996, 69, 791-793.	3.3	73
13	Calculating the linear response functions of noninteracting electrons with a time-dependent Schrödinger equation. Physical Review E, 1997, 56, 1222-1229.	2.1	68
14	Lasing action of $\text{Ga}_{0.67}\text{In}_{0.33}\text{As}/\text{GaInAsP}/\text{InP}$ tensile-strained quantum-box laser. Electronics Letters, 1994, 30, 142-143.	1.0	67
15	Efficient 230–280 nm emission from high-Al-content AlGaIn-based multi-quantum wells. Applied Physics Letters, 2002, 80, 37-39.	3.3	67
16	Analysis of current injection efficiency of separate-confinement-heterostructure quantum-film lasers. IEEE Journal of Quantum Electronics, 1992, 28, 68-74.	1.9	64
17	GaIn quantum-dot formation by self-assembling droplet epitaxy and application to single-electron transistors. Applied Physics Letters, 2001, 79, 2243-2245.	3.3	61
18	Three-dimensional photonic crystals for optical wavelengths assembled by micromanipulation. Applied Physics Letters, 2002, 81, 3122-3124.	3.3	57

#	ARTICLE	IF	CITATIONS
19	Carrier capture time and its effect on the efficiency of quantum-well lasers. IEEE Journal of Quantum Electronics, 1994, 30, 54-62.	1.9	51
20	High-Efficiency 352 nm Quaternary InAlGa _N -Based Ultraviolet Light-Emitting Diodes Grown on GaN Substrates. Japanese Journal of Applied Physics, 2004, 43, L1241-L1243.	1.5	51
21	New Technique for Fabrication of Two-Dimensional Photonic Bandgap Crystals by Selective Epitaxy. Japanese Journal of Applied Physics, 1997, 36, L286-L288.	1.5	48
22	External Quantum Efficiency of 6.5% at 300 nm Emission and 4.7% at 310 nm Emission on Bare Wafer of AlGa _N -Based UVB LEDs. ACS Applied Electronic Materials, 2020, 2, 1892-1907.	4.3	45
23	Estimation of carrier capture time of quantum-well lasers by spontaneous emission spectra. Applied Physics Letters, 1992, 61, 2398-2400.	3.3	43
24	High hole carrier concentration realized by alternative co-doping technique in metal organic chemical vapor deposition. Applied Physics Letters, 2011, 99, .	3.3	33
25	Room-temperature operation of GaInAs/GaInAsP/InP SCH lasers with quantum-wire size active region. IEEE Journal of Quantum Electronics, 1993, 29, 2123-2133.	1.9	30
26	High internal quantum efficiency and optically pumped stimulated emission in AlGa _N -based UV-C multiple quantum wells. Applied Physics Letters, 2020, 117, .	3.3	28
27	Growth and Optical Properties of Quaternary InAlGa _N for 300 nm Band UV-Emitting Devices. Physica Status Solidi A, 2001, 188, 83-89.	1.7	27
28	Beyond 53% internal quantum efficiency in a AlGa _N quantum well at 326-nm UVA emission and single-peak operation of UVA LED. Optics Letters, 2020, 45, 495.	3.3	26
29	Realization of 340-nm-Band High-Output-Power (>7 mW) InAlGa _N Quantum Well Ultraviolet Light-Emitting Diode with p-Type InAlGa _N . Japanese Journal of Applied Physics, 2008, 47, 2941-2944.	1.5	24
30	Effects of In composition on ultraviolet emission efficiency in quaternary InAlGa _N light-emitting diodes on freestanding GaN substrates and sapphire substrates. Journal of Applied Physics, 2005, 98, 113514.	2.5	23
31	Correlation between excitons recombination dynamics and internal quantum efficiency of AlGa _N -based UV-A multiple quantum wells. Journal of Applied Physics, 2020, 128, .	2.5	23
32	Determination of built-in electric fields in quaternary InAlGa _N heterostructures. Applied Physics Letters, 2003, 82, 1541-1543.	3.3	22
33	Improved crystal quality of semipolar AlN by employing a thermal annealing technique with MOVPE. Journal of Crystal Growth, 2019, 507, 307-309.	1.5	22
34	Milliwatt power UV-A LEDs developed by using n-AlGa _N superlattice buffer layers grown on AlN templates. Journal Physics D: Applied Physics, 2019, 52, 115102.	2.8	21
35	Formation of GaN nanopillars by selective area growth using ammonia gas source molecular beam epitaxy. Journal of Crystal Growth, 2002, 243, 129-133.	1.5	19
36	Fabrication of a-Plane GaN Substrate Using the Sr-Na Flux Liquid Phase Epitaxy Technique. Japanese Journal of Applied Physics, 2007, 46, L103-L106.	1.5	18

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37	Smart Wide-Bandgap Omnidirectional Reflector as an Effective Hole-Injection Electrode for Deep-UV Light-Emitting Diodes. <i>Advanced Optical Materials</i> , 2020, 8, 1901430.	7.3	18
38	Influence of residual oxygen impurity in quaternary InAlGaN multiple-quantum-well active layers on emission efficiency of ultraviolet light-emitting diodes on GaN substrates. <i>Journal of Applied Physics</i> , 2006, 99, 114509.	2.5	17
39	Liquid Phase Epitaxy Growth of m-Plane GaN Substrate Using the Na Flux Method. <i>Japanese Journal of Applied Physics</i> , 2007, 46, L227-L229.	1.5	17
40	Fabrication of a low-threading-dislocation-density Al _x Ga _{1-x} N buffer on SiC using highly Si-doped Al _x Ga _{1-x} N superlattices. <i>Applied Physics Letters</i> , 2002, 80, 2057-2059.	3.3	16
41	Effect of Thermal Annealing on the Pd/Au Contact to P-Type Al _{0.15} Ga _{0.85} N. <i>Japanese Journal of Applied Physics</i> , 2002, 41, 581-582.	1.5	16
42	Improvement of operation temperature in GaAs/AlGaAs THz-QCLs by utilizing high Al composition barrier. <i>Physica Status Solidi C: Current Topics in Solid State Physics</i> , 2013, 10, 1430-1433.	0.8	15
43	Influence of the nucleation conditions on the quality of AlN layers with high-temperature annealing and regrowth processes. <i>Japanese Journal of Applied Physics</i> , 2019, 58, SC1056.	1.5	15
44	Controlled crystal orientations of semipolar AlN grown on an <i>m</i> -plane sapphire by MOCVD. <i>Japanese Journal of Applied Physics</i> , 2019, 58, SC1031.	1.5	15
45	Advantages of GaN Substrates in InAlGaN Quaternary Ultraviolet-Light-Emitting Diodes. <i>Japanese Journal of Applied Physics</i> , 2004, 43, 8030-8031.	1.5	14
46	Improvement of Regrown Interface in InP Organo-Metallic Vapor Phase Epitaxy. <i>Japanese Journal of Applied Physics</i> , 1991, 30, L672-L674.	1.5	13
47	230 to 250 nm Intense Emission from AlN/AlGaN Quantum Wells. <i>Physica Status Solidi A</i> , 2000, 180, 157-161.	1.7	13
48	High-quality AlN template grown on a patterned Si(111) substrate. <i>Journal of Crystal Growth</i> , 2017, 468, 225-229.	1.5	13
49	Room temperature operation of GaInAs-GaInAsP-InP SCH multiquantum-film laser with narrow wire-like active region. <i>IEEE Photonics Technology Letters</i> , 1991, 3, 191-192.	2.5	12
50	Novel spontaneous emission control using 3-dimensional photonic bandgap crystal cavity. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 1998, 51, 99-102.	3.5	12
51	The Utility of Droplet Elimination by Thermal Annealing Technique for Fabrication of GaN/AlGaN Terahertz Quantum Cascade Structure by Radio Frequency Molecular Beam Epitaxy. <i>Applied Physics Express</i> , 2010, 3, 125501.	2.4	12
52	Impact of thermal treatment on the growth of semipolar AlN on <i>m</i> -plane sapphire. <i>AIP Advances</i> , 2018, 8, .	1.3	12
53	High-efficiency 350 nm-band quaternary InAlGaN-based UV-LED on GaN/sapphire template. <i>Physica Status Solidi C: Current Topics in Solid State Physics</i> , 2005, 2, 2899-2902.	0.8	11
54	Optimization of terahertz quantum cascade lasers by suppressing carrier leakage channel via high-energy state. <i>Applied Physics Express</i> , 2018, 11, 112702.	2.4	11

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55	Research status and prospects of deep ultraviolet devices. <i>Journal of Semiconductors</i> , 2019, 40, 120301.	3.7	11
56	Nonradiative centers in deep-UV AlGaIn-based quantum wells revealed by two-wavelength excited photoluminescence. <i>Physica Status Solidi (B): Basic Research</i> , 2015, 252, 936-939.	1.5	10
57	Growth of AlN-SiC solid solutions by sequential supply epitaxy. <i>Journal of Crystal Growth</i> , 2002, 234, 435-439.	1.5	9
58	1.9 THz selective injection design quantum cascade laser operating at extreme higher temperature above the $k_B T$ line. <i>Physica Status Solidi C: Current Topics in Solid State Physics</i> , 2013, 10, 1448-1451.	0.8	9
59	Effects of Ga Supply on the Growth of (11 $\bar{2}$ 2) AlN on c -Plane (10 $\bar{1}$ 0) Sapphire Substrates. <i>Physica Status Solidi (B): Basic Research</i> , 2018, 255, 1700418.	1.5	9
60	Reflectance of a reflective photonic crystal p-contact layer for improving the light-extraction efficiency of AlGaIn-based deep-ultraviolet light-emitting diodes. <i>AIP Advances</i> , 2018, 8, 125126.	1.3	8
61	Evolution of morphology and crystalline quality of DC-sputtered AlN films with high-temperature annealing. <i>Japanese Journal of Applied Physics</i> , 2019, 58, SC1029.	1.5	8
62	Effects of GaN substrates on InAlGaIn quaternary UV LEDs. <i>Physica Status Solidi A</i> , 2004, 201, 2624-2627.	1.7	7
63	Milliwatt Power 350 nm-band Quaternary InAlGaIn UV-LEDs on GaN Substrates. <i>Physica Status Solidi A</i> , 2004, 201, 2639-2643.	1.7	7
64	Growth of High-Quality AlN on Sapphire and Development of AlGaIn-Based Deep-Ultraviolet Light-Emitting Diodes. <i>Semiconductors and Semimetals</i> , 2017, 96, 85-120.	0.7	7
65	Beyond 53% internal quantum efficiency in a AlGaIn quantum well at 326-nm UVA emission and single-peak operation of UVA LED: publisher's note. <i>Optics Letters</i> , 2020, 45, 2563.	3.3	7
66	Threshold current reduction of GaInAs/GaInAsP/InP SCH quantum-well lasers with wire-like active region by using p-type substrates. <i>IEEE Photonics Technology Letters</i> , 1992, 4, 964-966.	2.5	6
67	Growth and annealing conditions of high Al-content p-type AlGaIn for deep-UV LEDs. <i>Physica Status Solidi A</i> , 2004, 201, 2803-2807.	1.7	6
68	Influence of the Strain Relaxation on the Optical Property of AlGaIn Quantum Wells. <i>Physica Status Solidi (B): Basic Research</i> , 2020, 257, 1900582.	1.5	5
69	High-efficiency UV LEDs using quaternary InAlGaIn. <i>Electrical Engineering in Japan (English Translation)</i> Tj ETQq1 1 0,784314 pgBT /Over	0.4	4
70	Ag-Metal Bonding Conditions for Low-Loss Double-Metal Waveguide for Terahertz Quantum Cascade Laser. <i>Japanese Journal of Applied Physics</i> , 2008, 47, 7926.	1.5	4
71	Nonradiative recombination centers in deep UV-wavelength AlGaIn quantum wells detected by below-gap excitation light. <i>Japanese Journal of Applied Physics</i> , 2019, 58, SCCB37.	1.5	4
72	Evaluation of GaN/AlGaIn THz quantum-cascade laser epi-layers grown on AlGaIn/Si templates by MOCVD. <i>Journal of Crystal Growth</i> , 2019, 510, 47-49.	1.5	4

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73	Enhanced Strain Relaxation in AlGaIn Layers Grown on Sputter-Based AlN Templates. <i>Physica Status Solidi (B): Basic Research</i> , 2020, 257, 1900590.	1.5	4
74	Hole capture rate of GaInAs/InP strained quantum-well lasers. <i>Optical and Quantum Electronics</i> , 1994, 26, S719-S729.	3.3	3
75	Growth mechanisms of GaN quantum dots and their optical properties. <i>Electronics and Communications in Japan</i> , 1998, 81, 20-26.	0.2	3
76	Quantum dot formation and crystal growth using an atomic nano-mask. <i>Physica E: Low-Dimensional Systems and Nanostructures</i> , 2001, 11, 89-93.	2.7	3
77	Surprisingly low built-in electric fields in quaternary AlInGaIn heterostructures. <i>Physica Status Solidi A</i> , 2004, 201, 190-194.	1.7	3
78	Comparison of Optical Properties between GaN and InGaIn Quantum Wells. <i>Physica Status Solidi (B): Basic Research</i> , 1999, 216, 287-290.	1.5	2
79	Significant improvements of quantum efficiency of quaternary InAlGaIn UV-LEDs on GaN substrates. <i>Physica Status Solidi C: Current Topics in Solid State Physics</i> , 2005, 2, 2912-2915.	0.8	2
80	Temperature dependence of nonradiative recombination processes in UV-B AlGaIn quantum well revealed by below-gap excitation light. <i>Optical Materials</i> , 2020, 105, 109878.	3.6	2
81	Emission Energy Shift in GaInAs/GaInAsP Strained Quantum-Box Structures Due to 0-Dimensional Quantum-Box Effect. <i>Japanese Journal of Applied Physics</i> , 1994, 33, 3571-3577.	1.5	1
82	Small Built-in Electric Fields in Quaternary InAlGaIn Heterostructures. <i>Physica Status Solidi (B): Basic Research</i> , 2002, 234, 764-768.	1.5	1
83	Random electric field induced by interface roughness in GaN/Al _x Ga _{1-x} N multiple quantum wells. <i>Applied Physics Express</i> , 2019, 12, 124005.	2.4	1